

FIG. 1

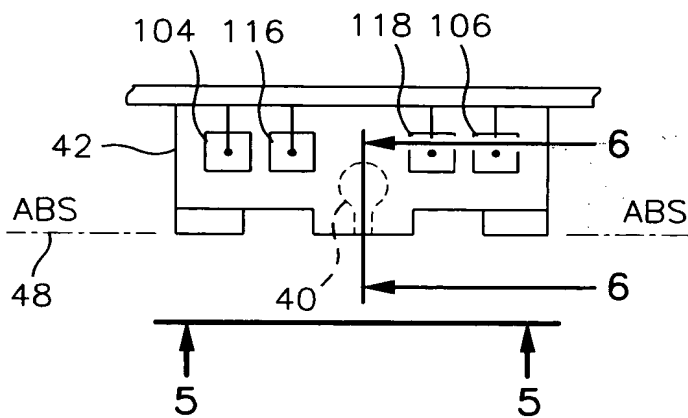
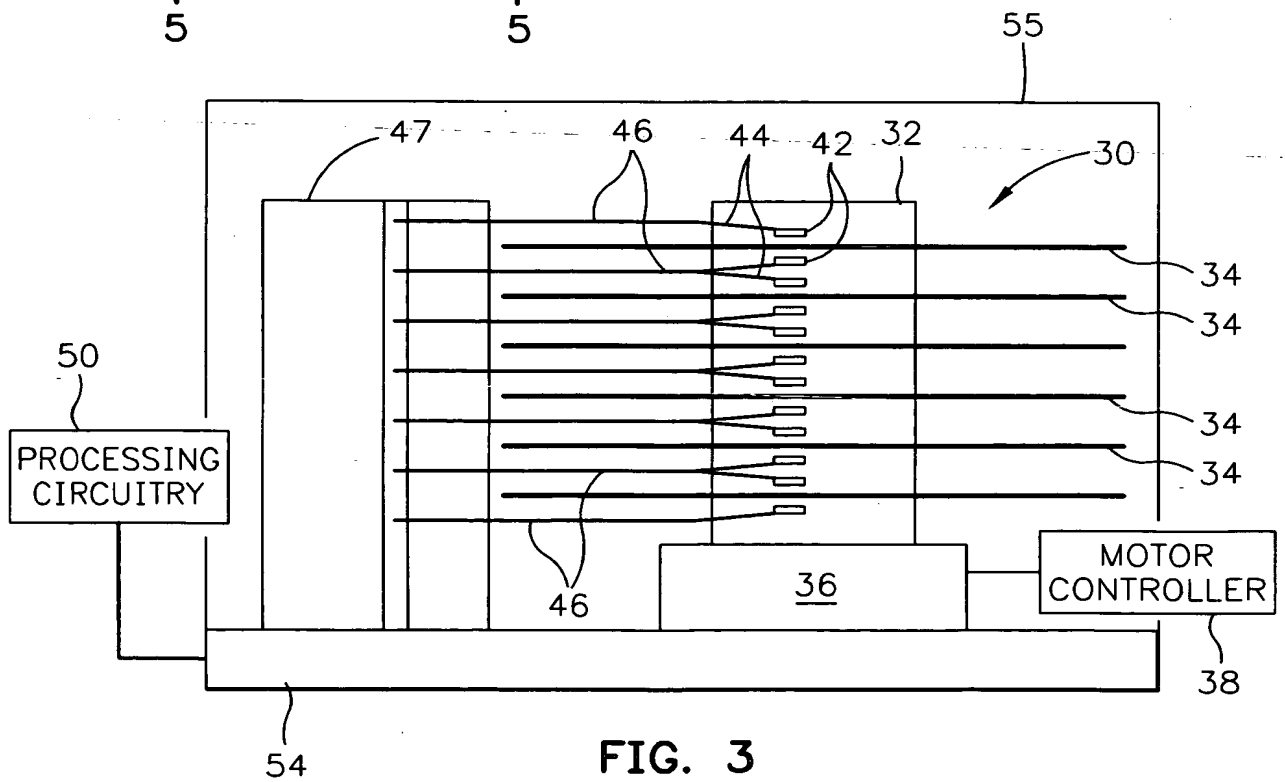


FIG. 2



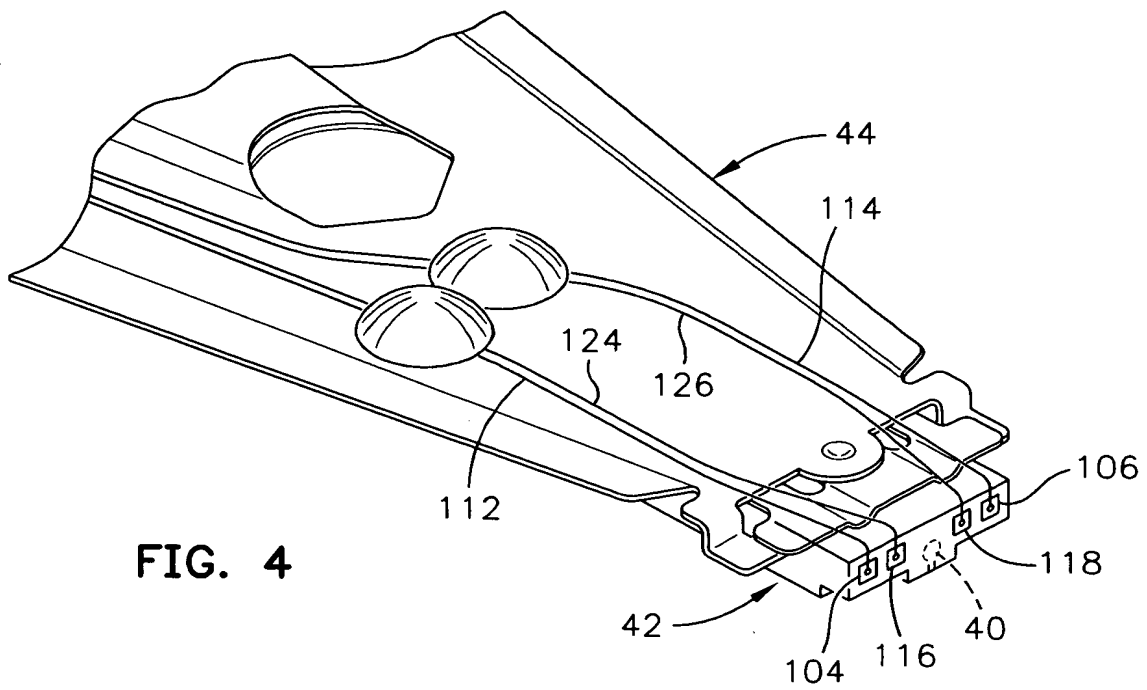


FIG. 4

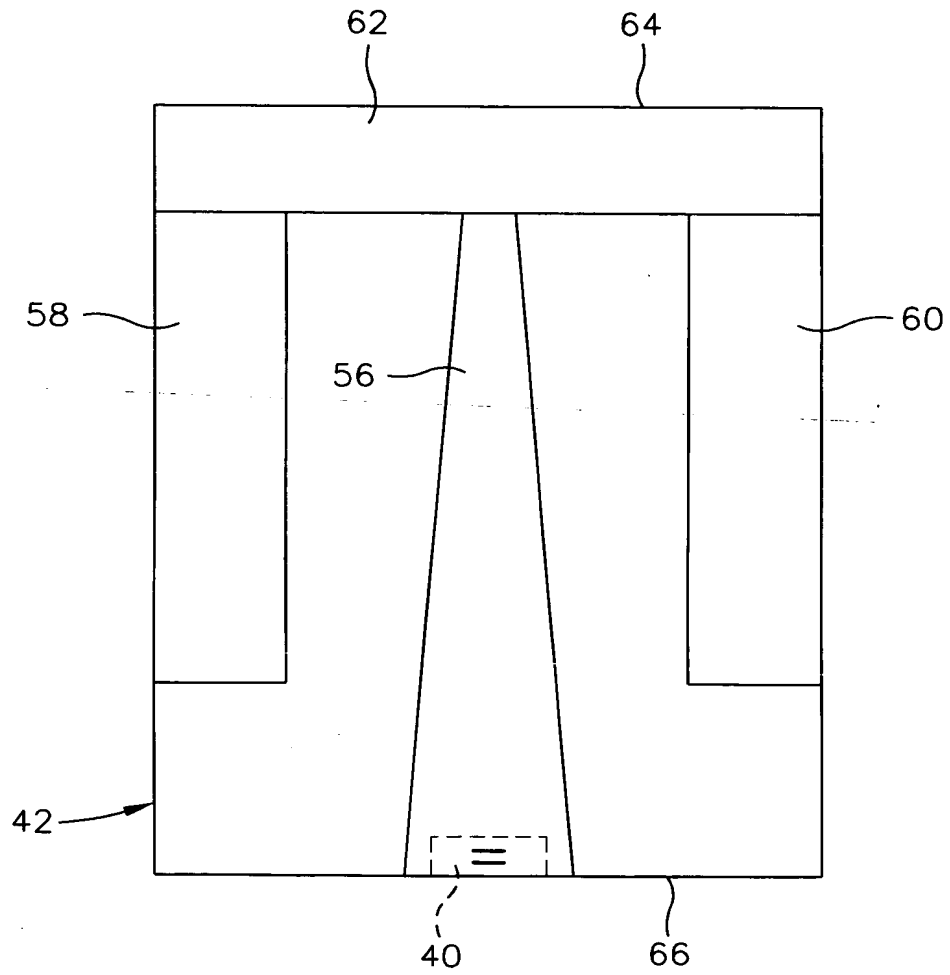


FIG. 5

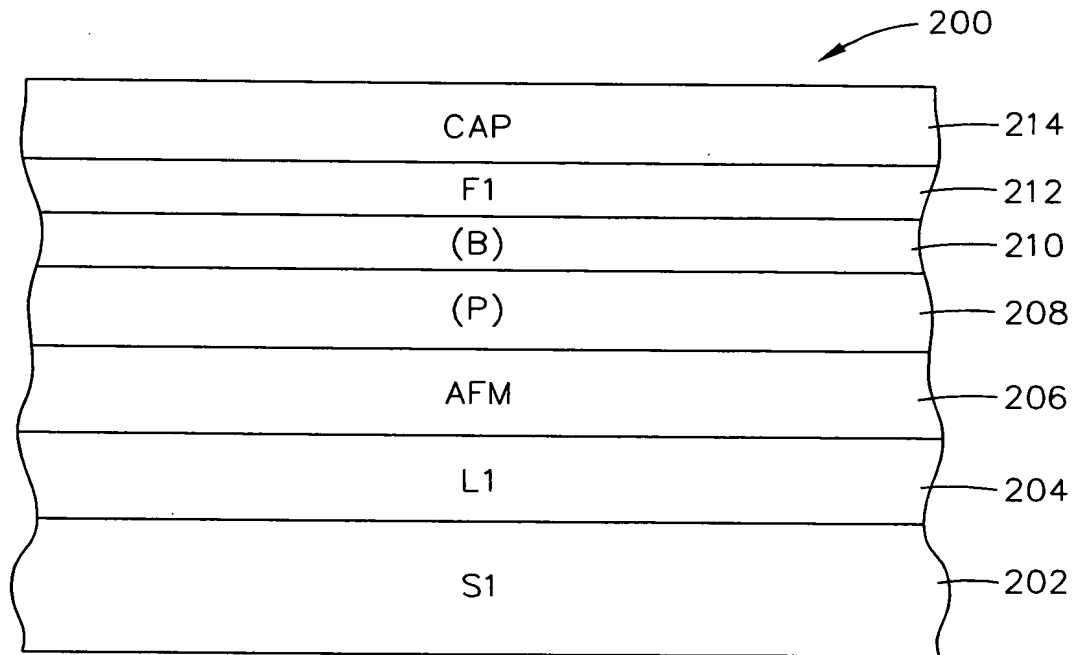


FIG. 9

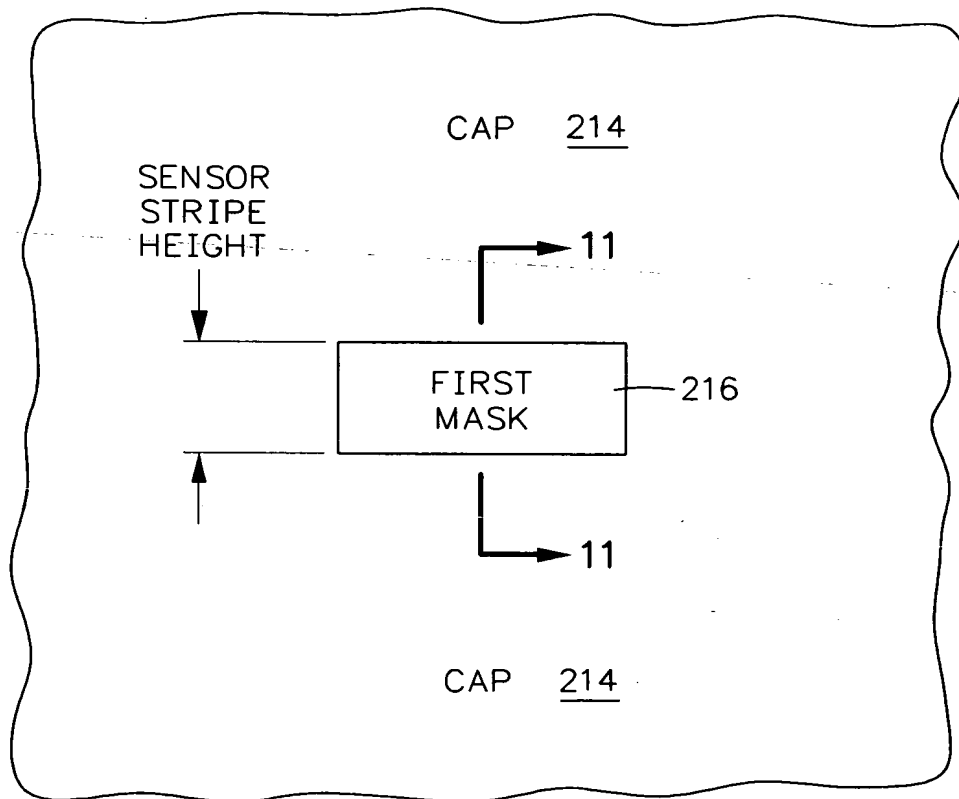


FIG. 10

10054352 011302

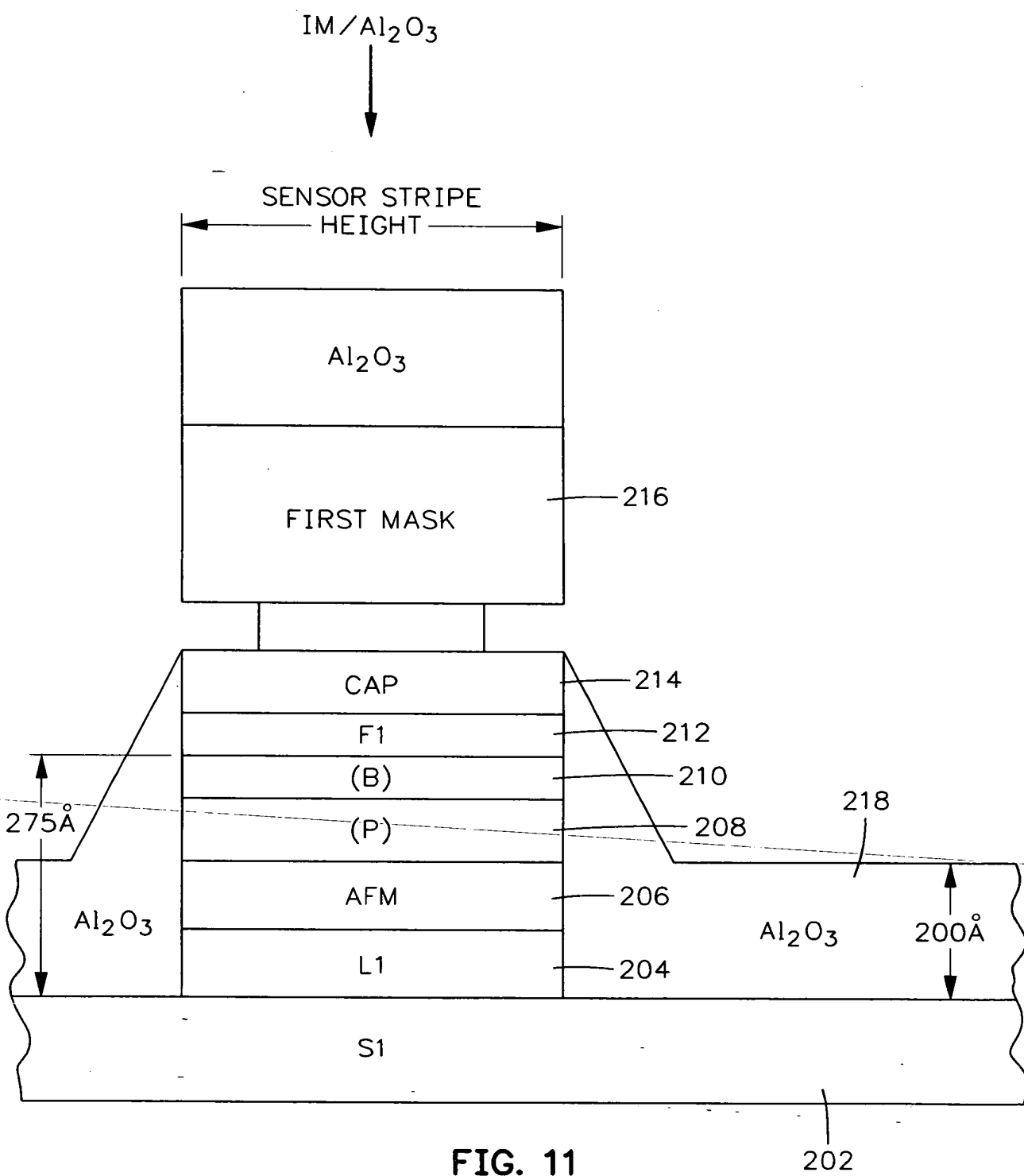


FIG. 11

REMOVE 1ST MASK AND SPUTTER ETCH AWAY CAP

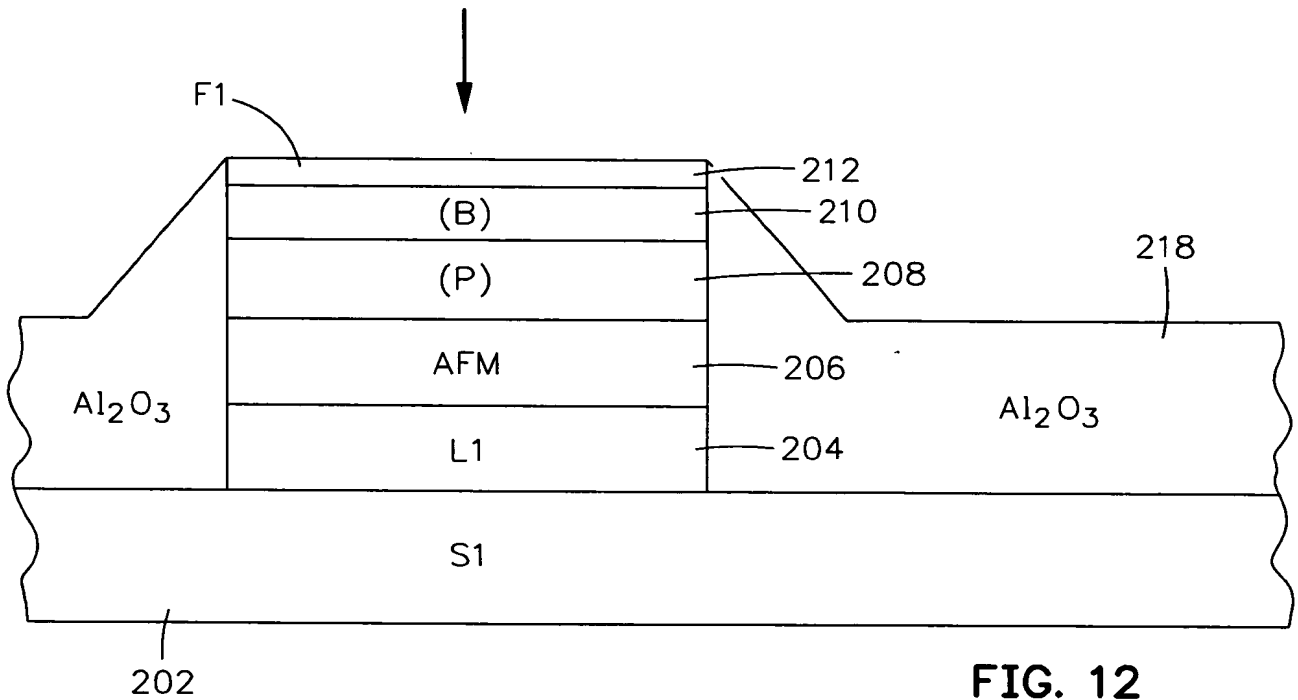


FIG. 12

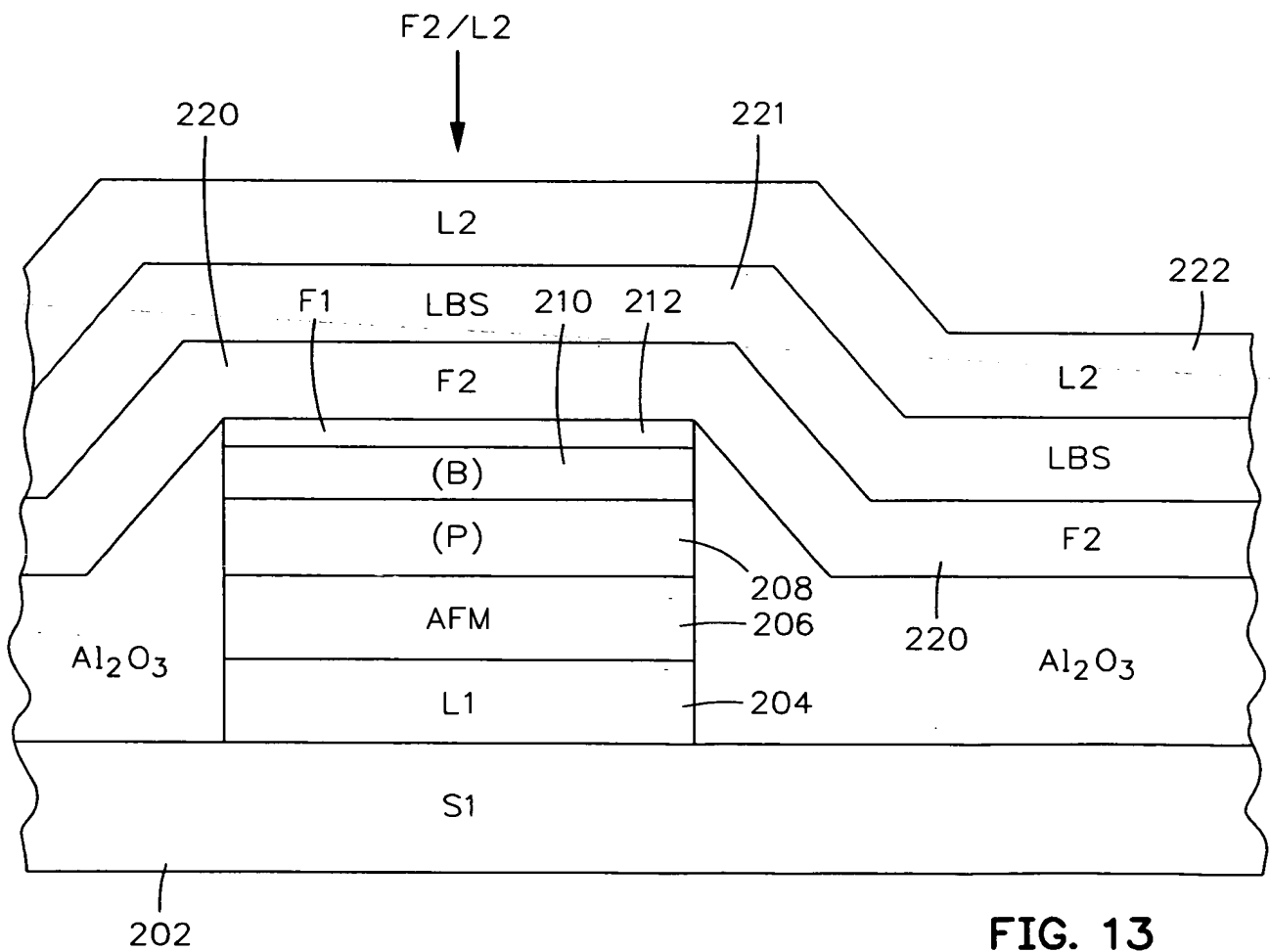


FIG. 13

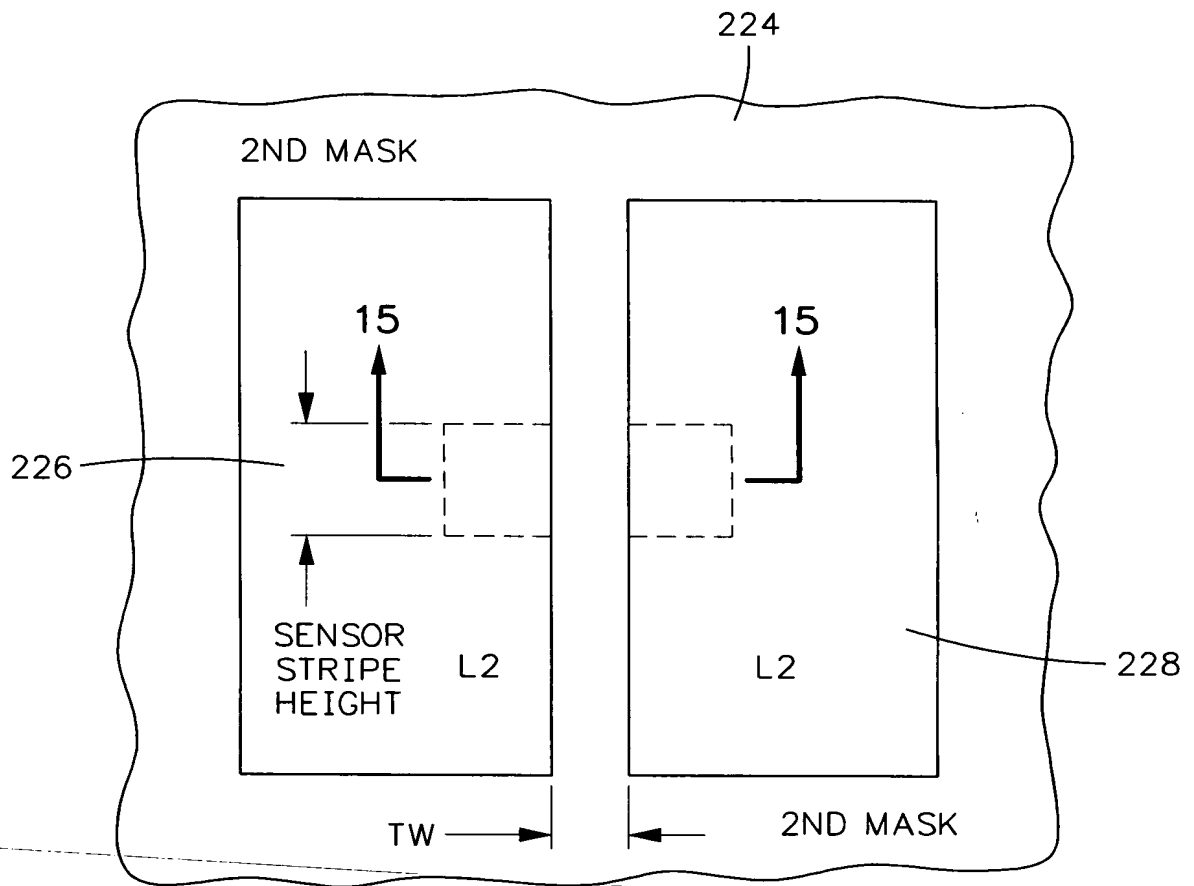


FIG. 14

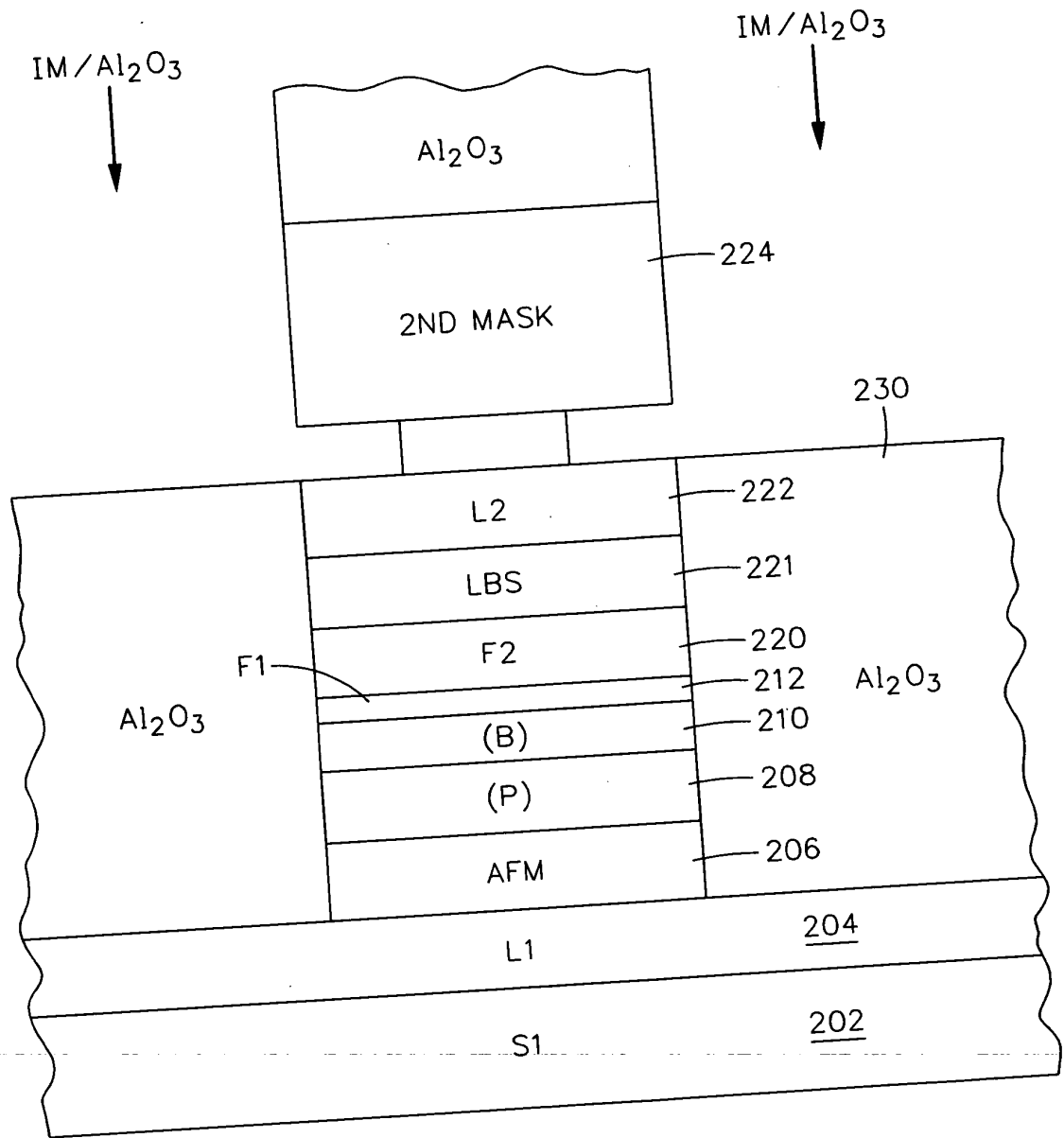


FIG. 15

REMOVE 2ND MASK
DEPOSIT S2

FIG. 16

10054353.01802

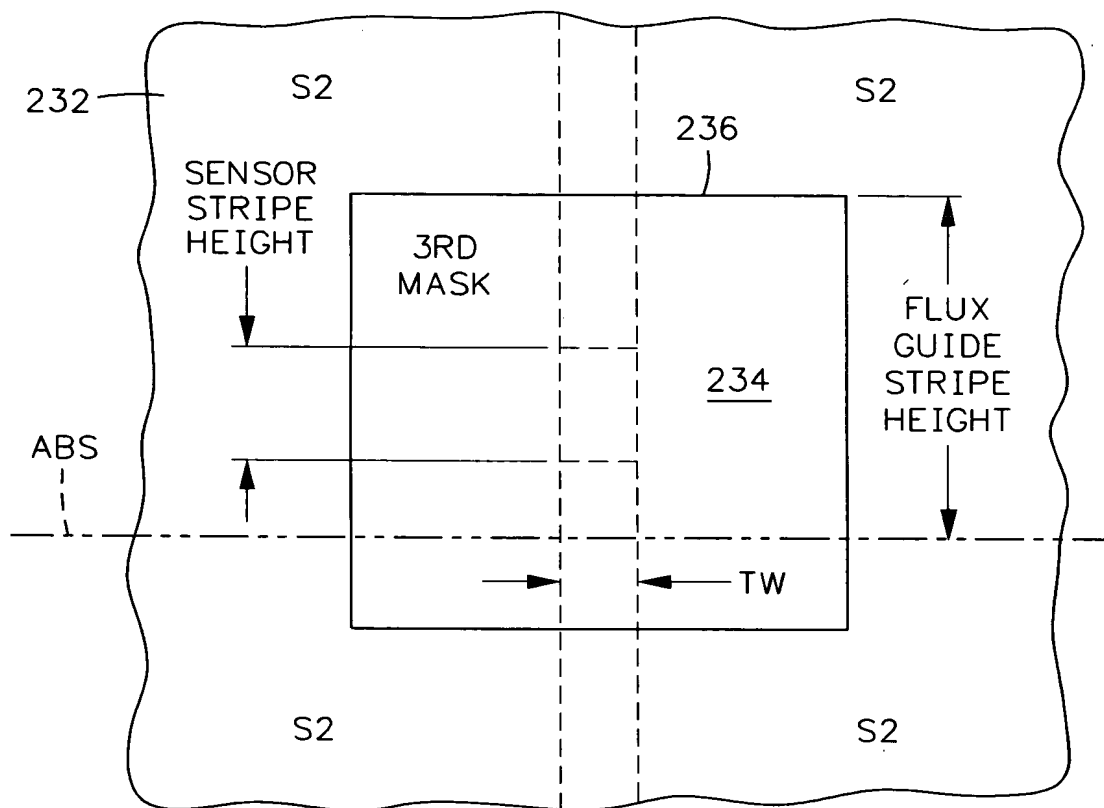


FIG. 17

ION MILL
REMOVE 3RD MASK

FIG. 18

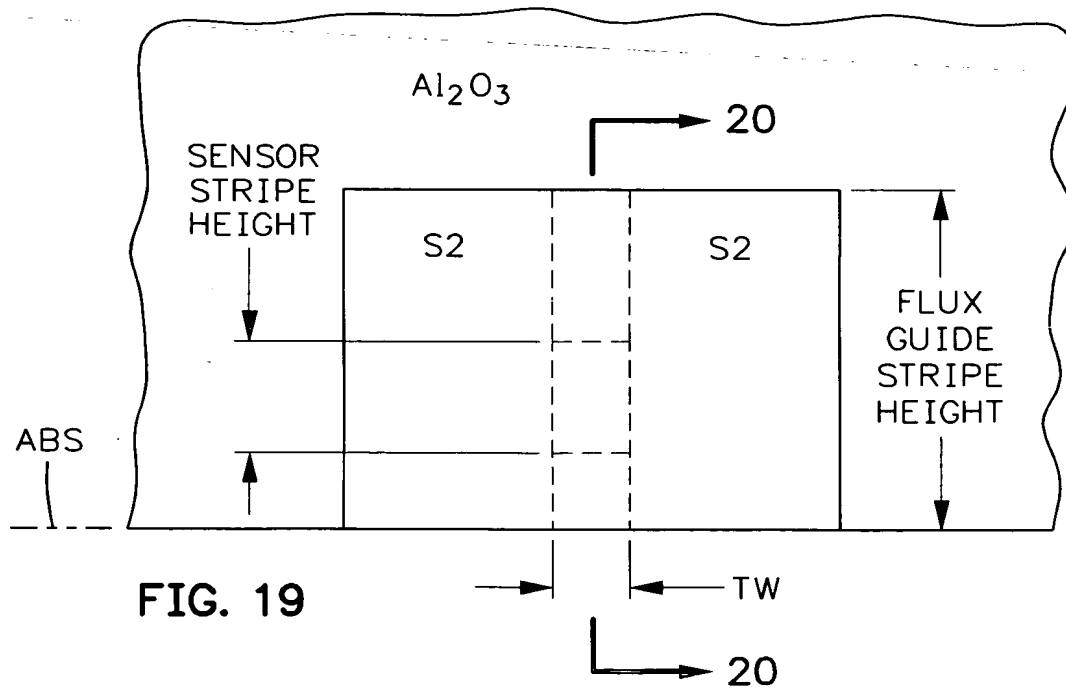


FIG. 19

20254355.01800

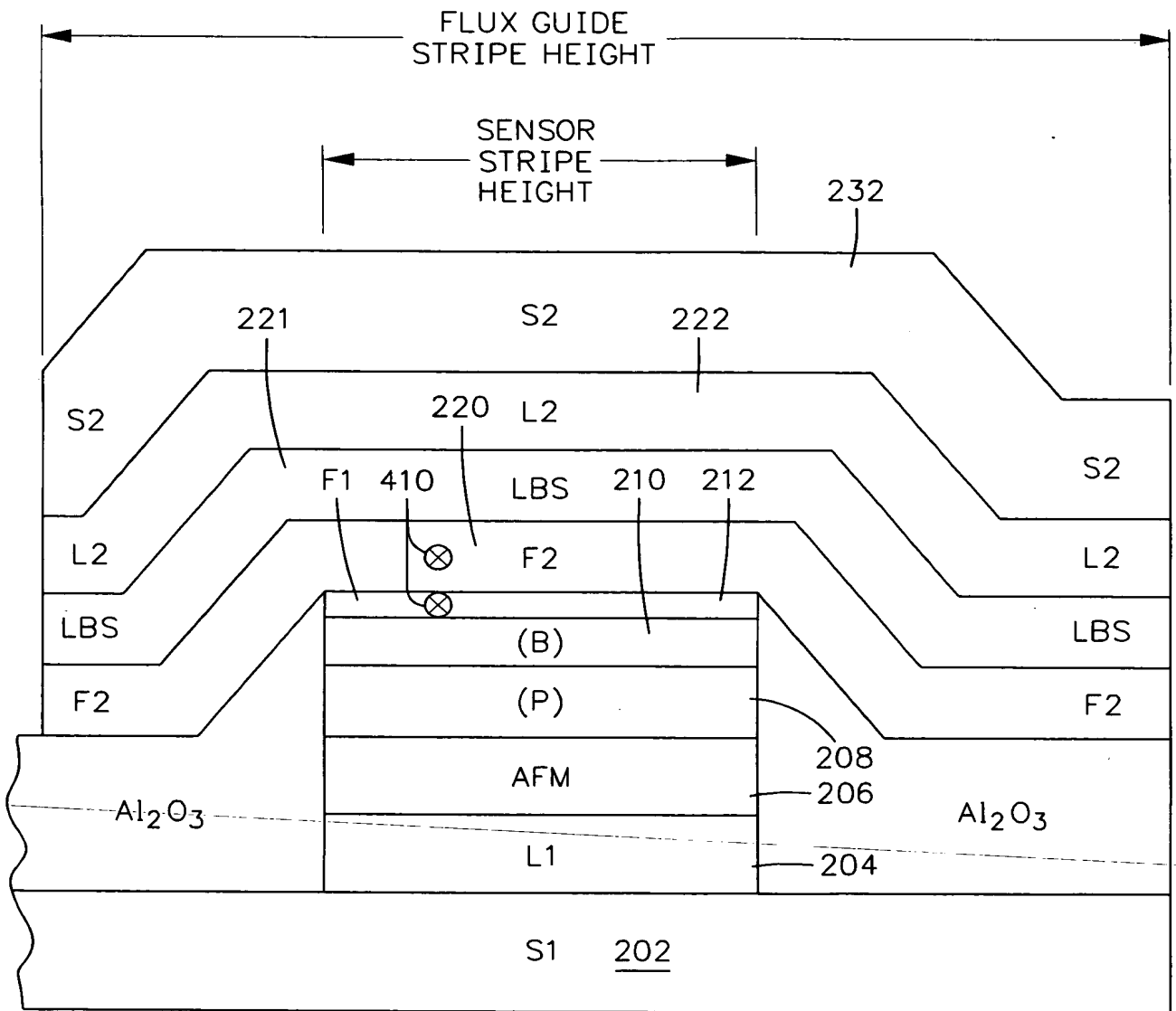


FIG. 20

ABS

20054932-01302

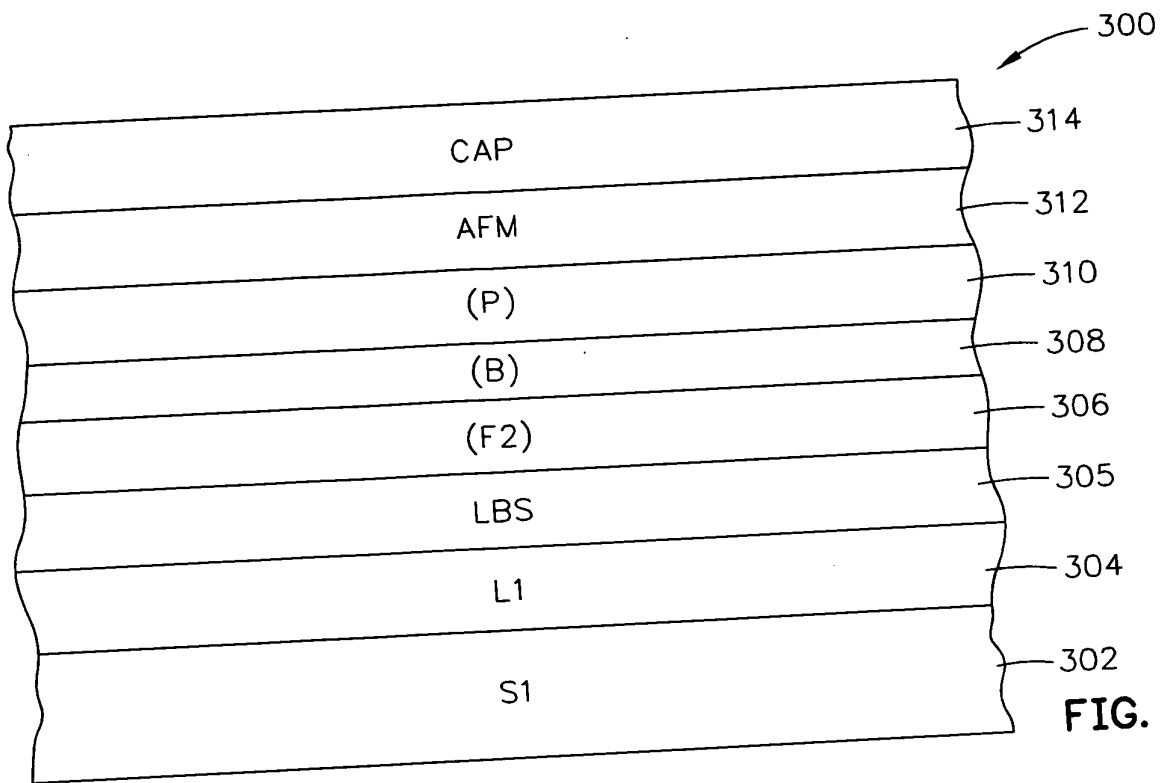


FIG. 21

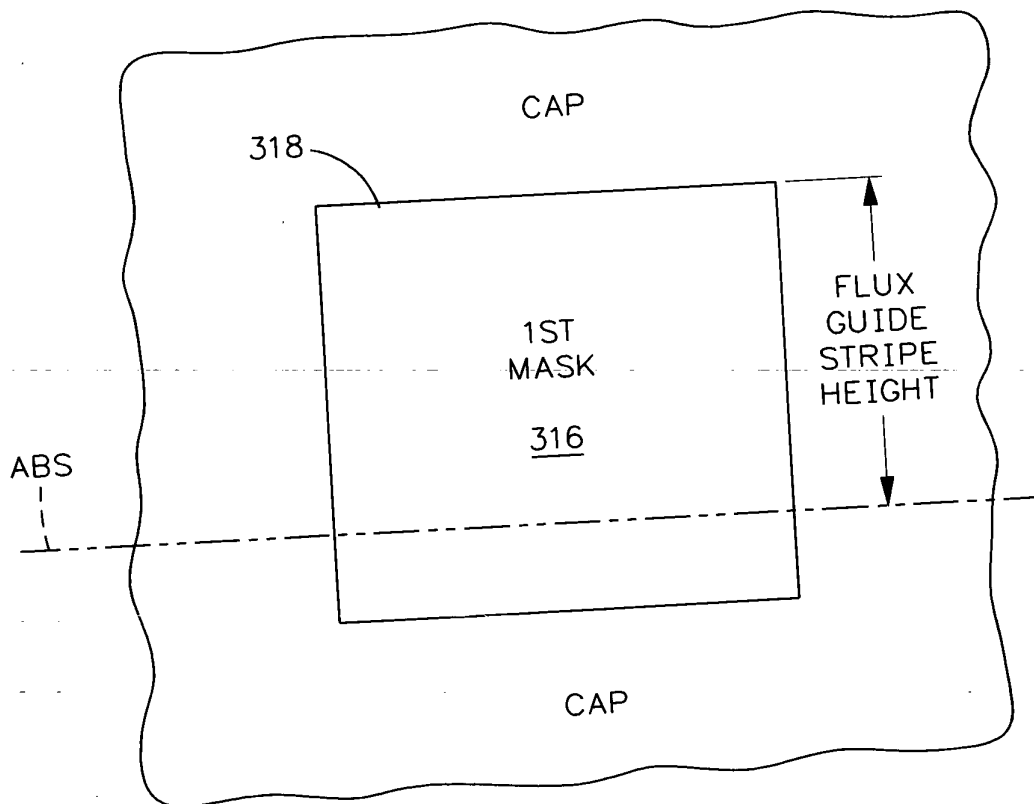


FIG. 22

ION MILL CAP
DEPOSIT ALUMINA
REMOVE 1ST MASK

FIG. 23

20054353.01802

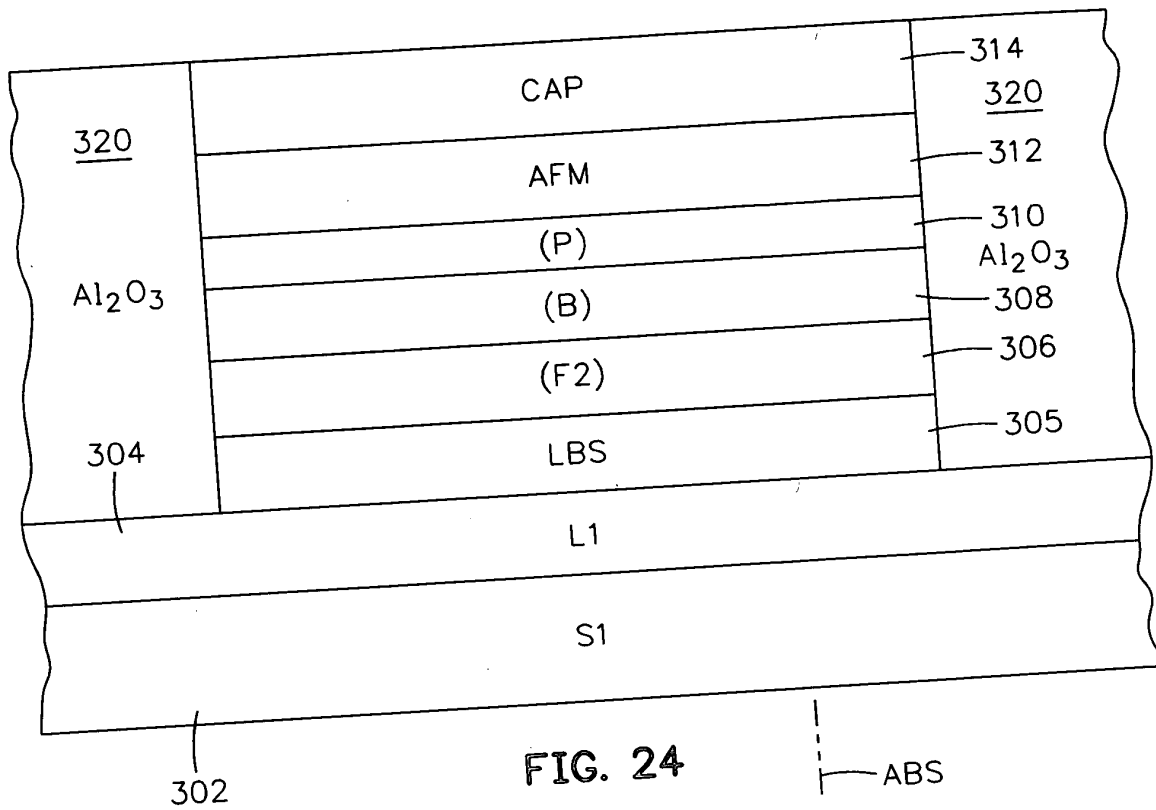


FIG. 24

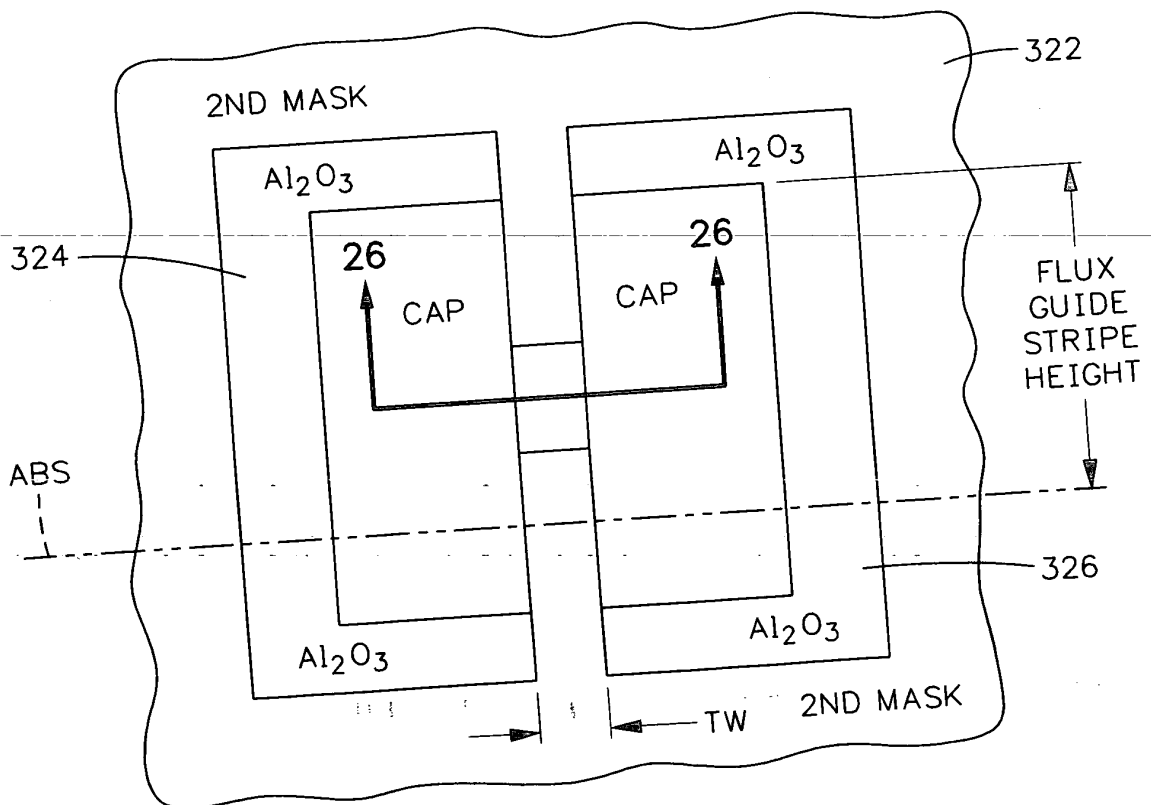


FIG. 25

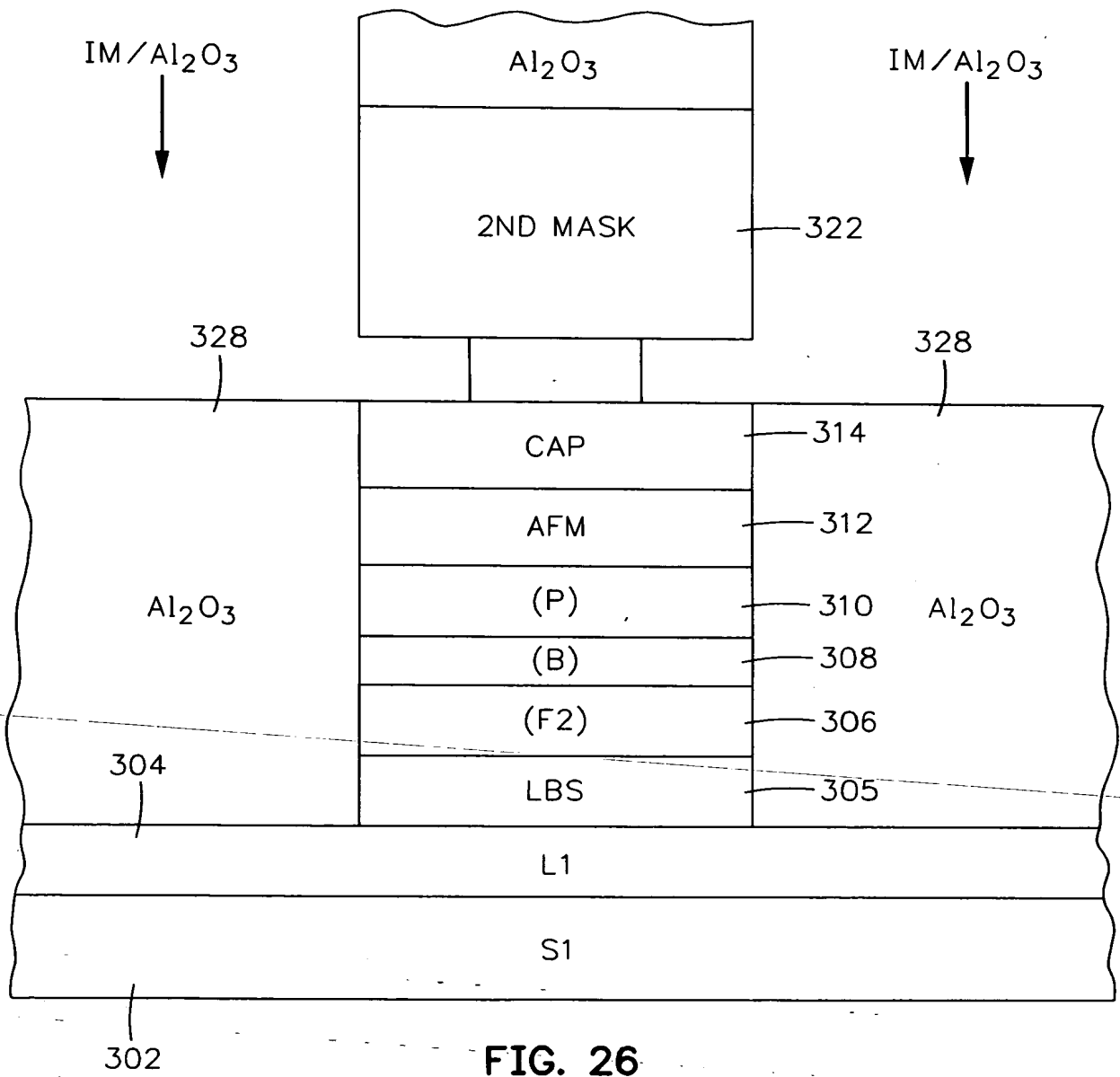
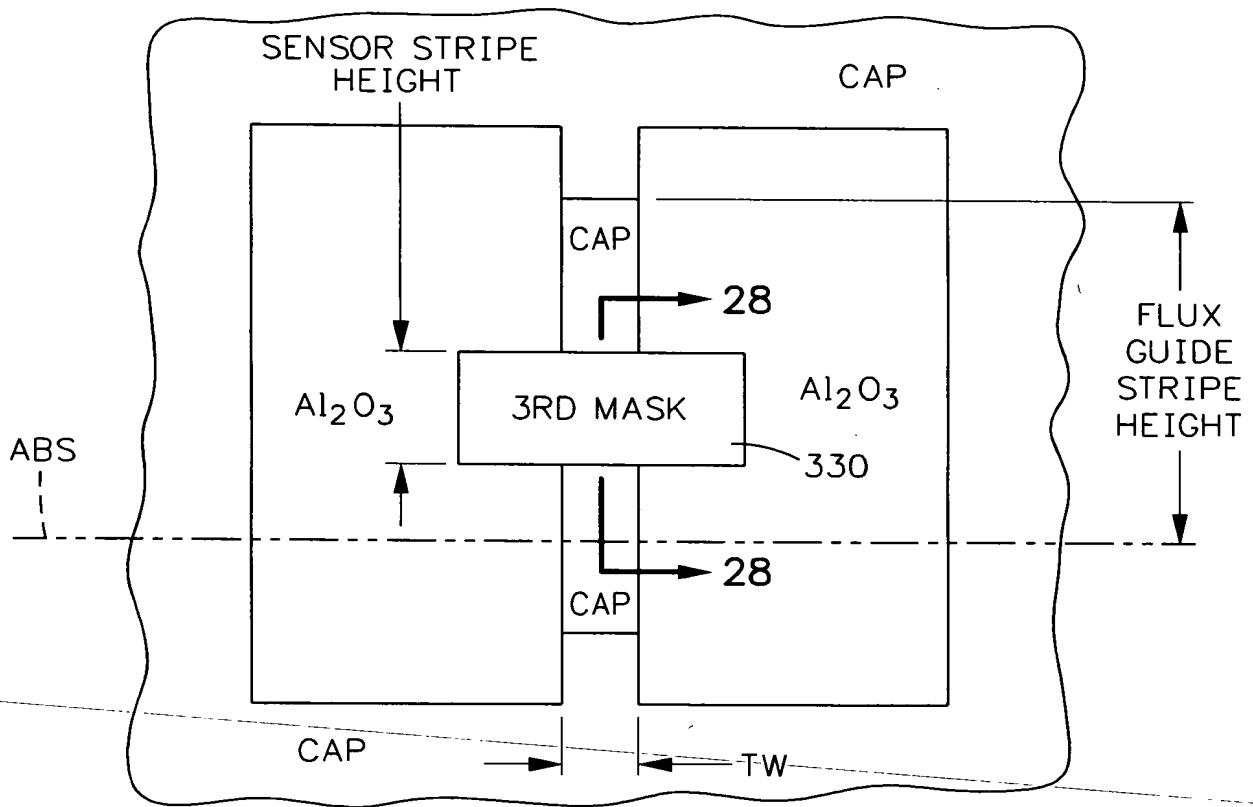


FIG. 26

FIG. 27.



10054352.018002

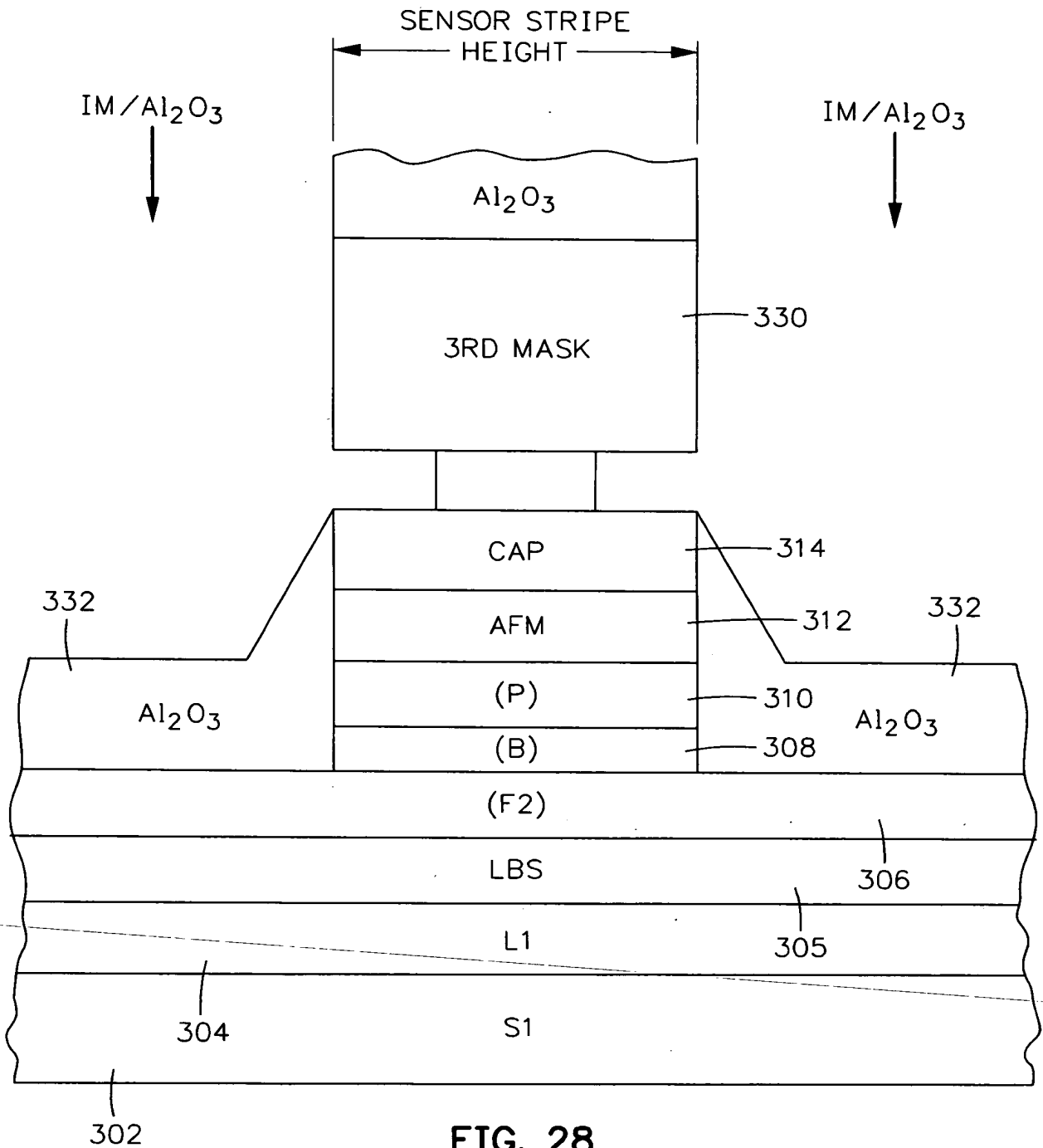


FIG. 28

REMOVE 3RD MASK
DEPOSIT L2/S2

FIG. 29

20254366.01802

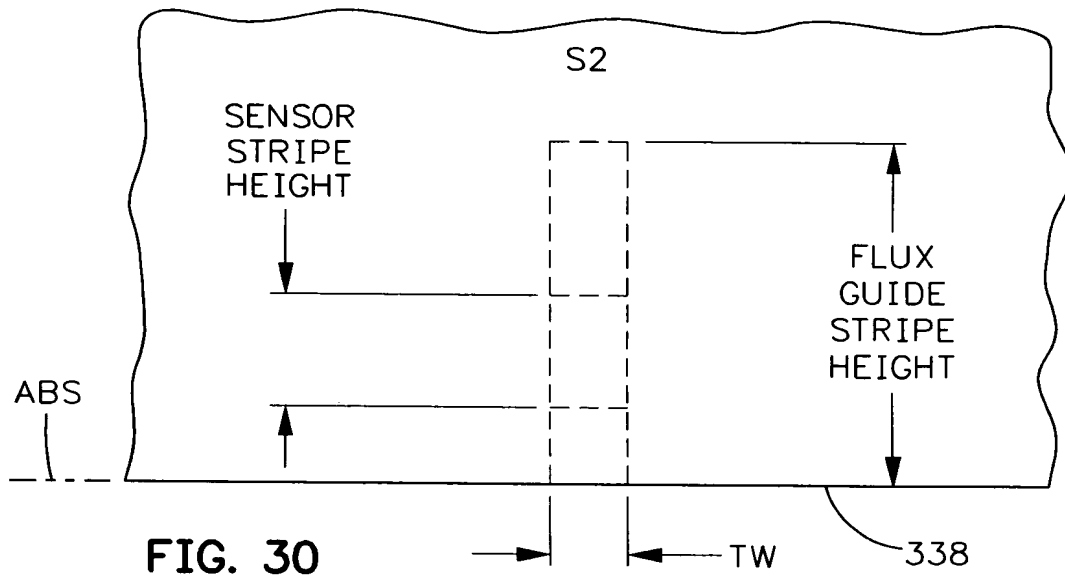


FIG. 30

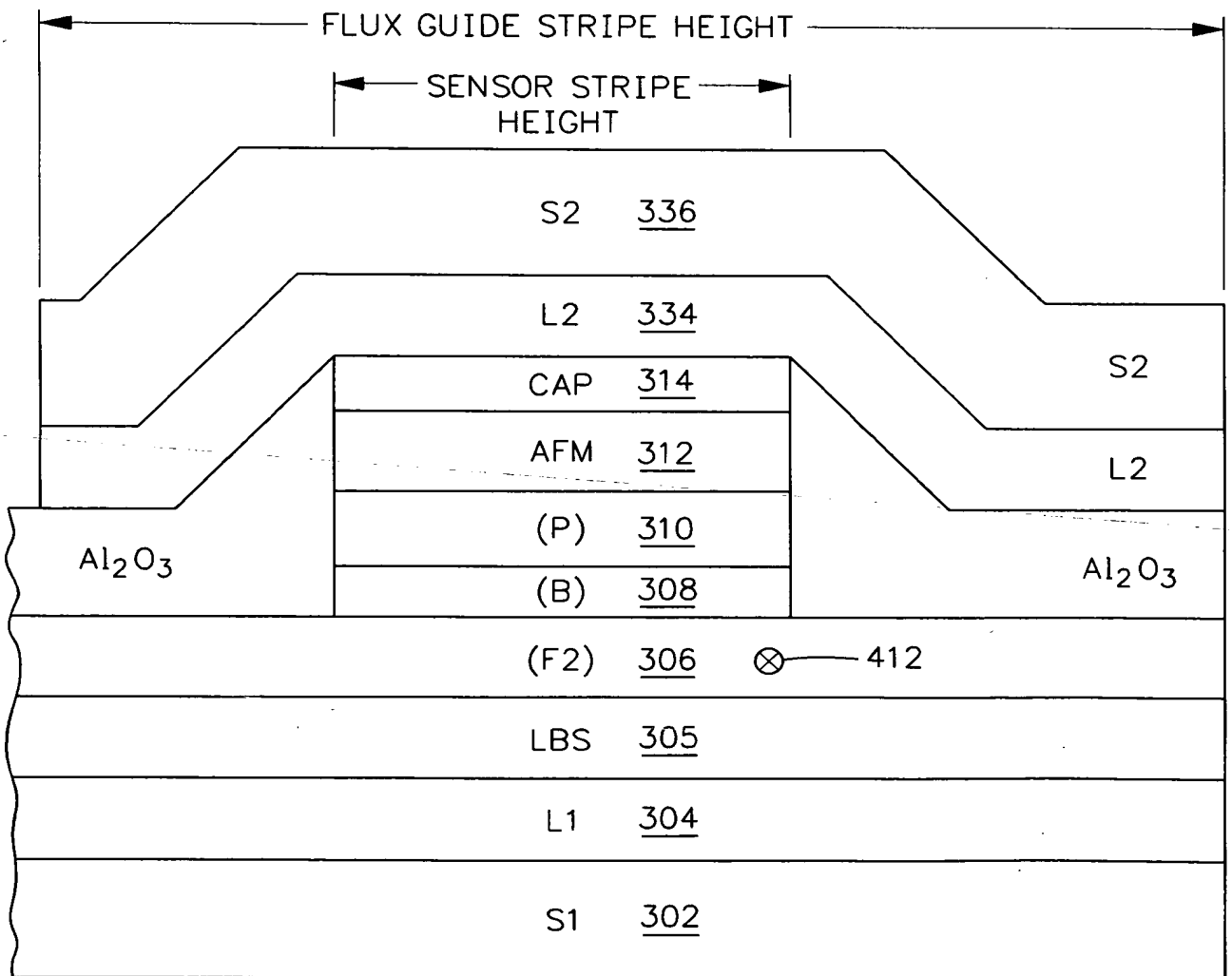


FIG. 31

ABS

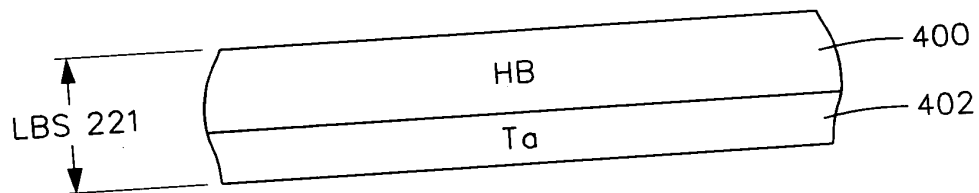


FIG. 32

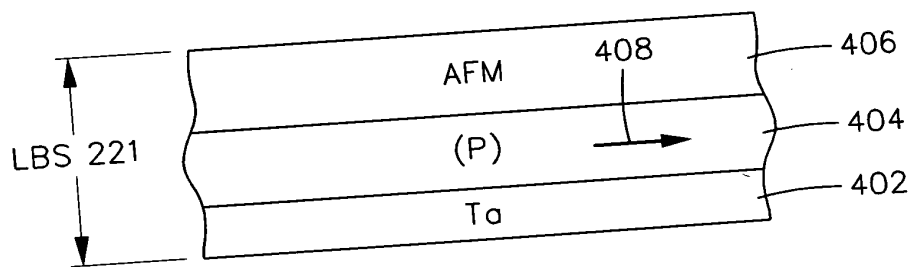


FIG. 33

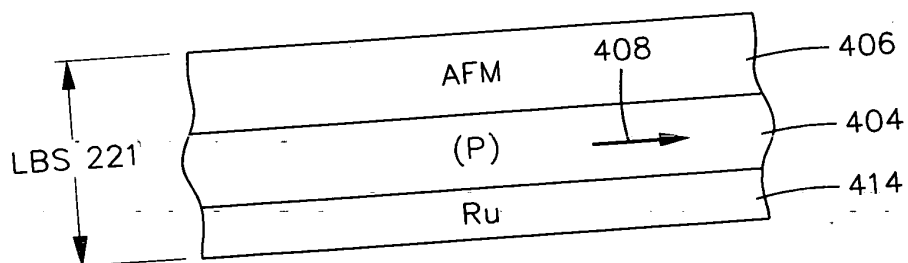


FIG. 34

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